

Development of SCRF Infrastructure at RRCAT

Satish Chandra Joshi

**Raja Ramanna Centre for Advanced Technology,
Indore, India**

IIFC Meeting at Fermi Lab, April 7-8, 2011

- Introduction of Plan Activity
- SCRF cavity fabrication
- Cavity Processing
- Building for Cavity Fabrication and Processing
- Development of Test Facilities
 - ✓ VTS
 - ✓ HTS



SCRF Infrastructure at RRCAT



Started in December 2007 under funding received from DAE for XI Plan Program

- **Motivation: Domestic & International Programs**
 1. Indian participation in ILC & Proton Driver.
 2. Superconducting Materials R & D for SCRF
 3. Development of SCRF Cavity Science and Technology including setting up a facilities that would be useful for development of cavities for HIPA.
 4. Application of SCRF including development of an infrared source to give coherent radiation using a superconducting post-accelerator.



Development of Superconducting Cavities and Associated Technologies for High Energy Accelerators and their Applications



Dt. of sanction	10th Dec., 2007
Sanctioned cost	~ USD 20 million
Expected completion date	31 st March, 2015

Project Objective :

- Technology development and setting up of an infrastructure for the SCRF cavity fabrication, chemical processing, cleaning, assembly and testing at required accelerating gradient for accelerator applications like XFEL, SNS, ERLs etc
- **To establish Cryogenic Infrastructure to operate large systems operating at liquid helium environment**
- Experimental research in bulk and thin film superconducting materials to find out what bestows the best superconducting properties from the point of building accelerating cavities with high gradient and high quality factor



SCRF Infrastructure Facility



- **During planning stage of SCRF Cavity Infrastructure Facility at RRCAT, important inputs were also received from SCRF facilities planned at Fermi National Accelerator Lab:**
 - **Clean room facility**
 - **Cavity RF Measurement techniques**
 - **Chemical Polishing of cavity (ANL)**
 - **Vertical Test Stand Facility**
 - **Horizontal Test Stand Facility**
 - **Electron beam welding machine specifications**
 - **Experience & exposure received during visit to Fermi lab**

Special thanks to colleagues at FNAL: Robert Kephart, Shekhar Mishra, Rich Stanek, Harry Carter, Tom Peterson, Mark Champion, Ruben Carcagno, Joe Ozelis, Camille Ginsburg, Cosmore Sylvester, Tug Arkan, Mike Foley, Charlie Cooper and many more.....



New Facilities Planned at RRCAT



SCRF cavity fabrication Facilities:

120 Ton Hydraulic Press, Nb machining, **EBW Machine** etc.

Chemical & thermal processing facilities

EP/BCP/CBP, **HPR & Annealing Furnaces** etc.,

Cavity Inspection Facilities

3-D CMM, **UTM**, **Optical inspection bench**, **3-D confocal microscope**, **SIMS**

Cavity RF Measurement & Tuning Facility

Half Cell, dumbell and multi-cell cavity frequency measurement

Cavity Frequency & field tuning machine (under planing)

Assembly & testing set up.

Clean-room, **Test cryostats**, **RF sources** etc.



Development of Cavity Fabrication facility

Developed forming tooling & process for 1.3 GHz SCRF cavity.



Forming



Inspection



Machining



Formed Niobium Half cell

120 T - HYDRAULIC PRESS

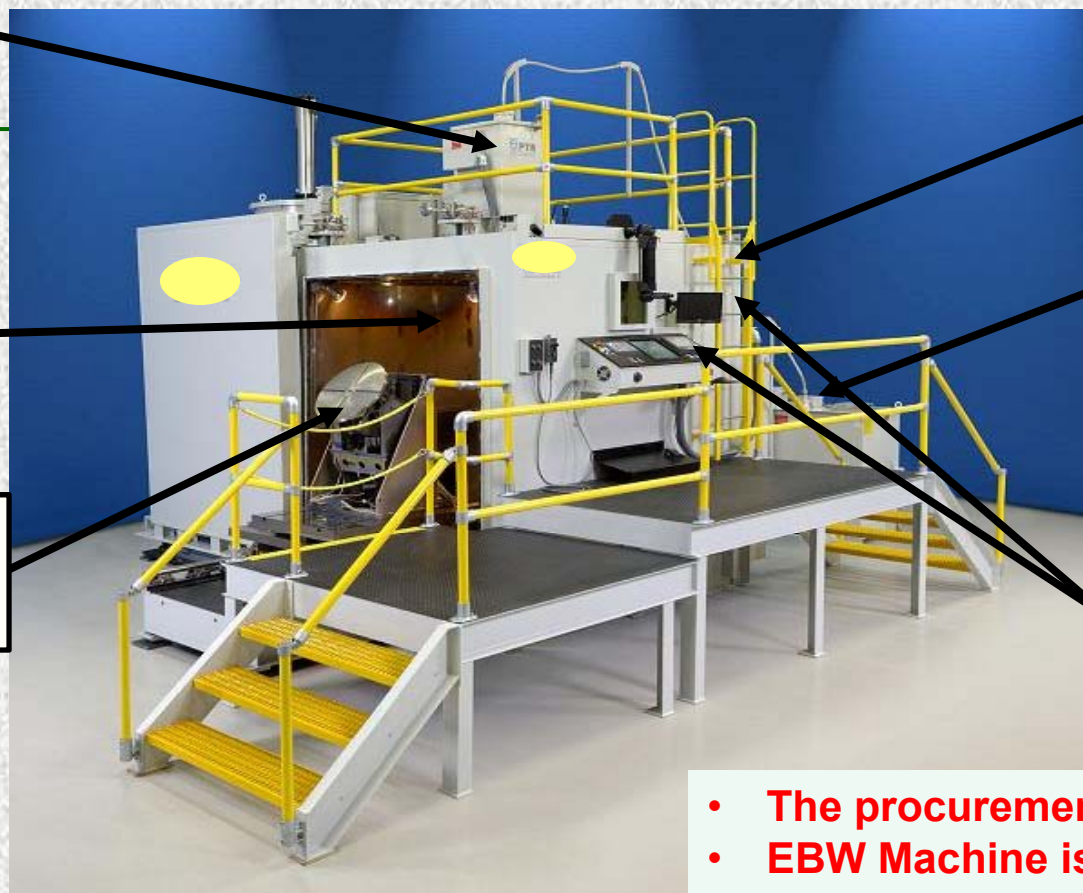


Electron Beam welding is required for manufacturing of SCRF cavities (low to high β range) made of high RRR Niobium for Proton Linac and other Accelerators to be developed at RRCAT.

EBW
Gun

Vacuum
Chamber

Work Table
with
Manipulator



High
Voltage
power
supply

Vacuum
System &
control
Electronics

Console &
Viewing
System

- The procurement is in process.
- EBW Machine is expected to be commissioned by mid 2013.



Fermilab

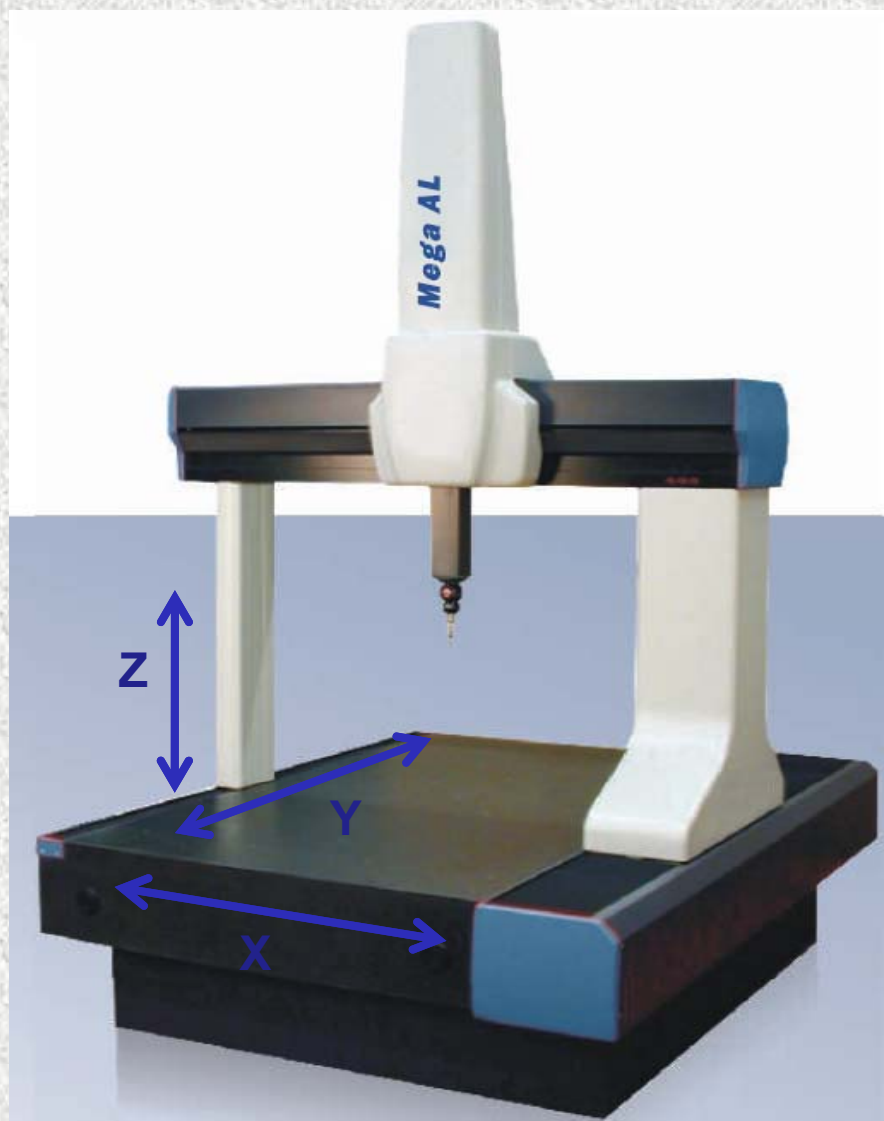
Major specifications of EBW Machine



Beam power	15 kW
Gun Voltage	90 to 150 kV
Duty cycle	100%
Beam current range	0 - 100 mA or wider
Beam current setting resolution	0.1 mA
Beam oscillations	1 – 1000 Hz or more
Beam deflection	$\pm 2.5^\circ$ min
Focus range	Ceiling to bottom of chamber, programmable
Beam focus diameter	0.25 mm or less
Inner size of chamber	3650 x 1500 x 1800 LxBxH mm ³ (min)
X-Y table size	1780 mm x 710 mm (nearest standard)
Travel of X Y table	1780 mm x 660 mm
Linear speed	1-2500 mm per minute
Vacuum ready pressure	$< 5 \times 10^{-4}$ mbar in 30 minutes
Ready for welding pressure	$< 2 \times 10^{-6}$ mbar in 60 minutes
Load Capacity	2500 kg
X – radiation leakage limit	less than 0.1 mR/hr at full accelerating voltage
Online optics	With CCD camera and suitable illumination system



Inspection, Measurement & Cavity Test Facility



Measuring Range		
X axis	1200 mm	
Y axis	2000 mm	
Z axis	1000 mm	
Accuracy	1.6 + L/400 μ m	
Resolution	0.1 μ m	
Measuring Table	Granite Surface Plate (Grade 0)	
Probing Systems	TP 20, SP 80, Laser Scanner	

Purchase Order placed on Aug 2010
 Expected Delivery – **March - 2011**

Instron UTM Model: 5569

- **Load:** ± 50 kN
- **Testing speed:** 0.001 – 500 mm/min
- **Accuracy of Load:** $\pm 0.5\%$ for 0.5 – 50 kN
- **Strain measurement Accuracy: ASTM E 83 Class B or better**
- **Total cross head travel:** 1500 mm

Measurements:

- Yield strength, ultimate tensile strength
- Elongation
- Plastic strain ratio, Strain hardening exponent.
- Cavity Stiffness measurement



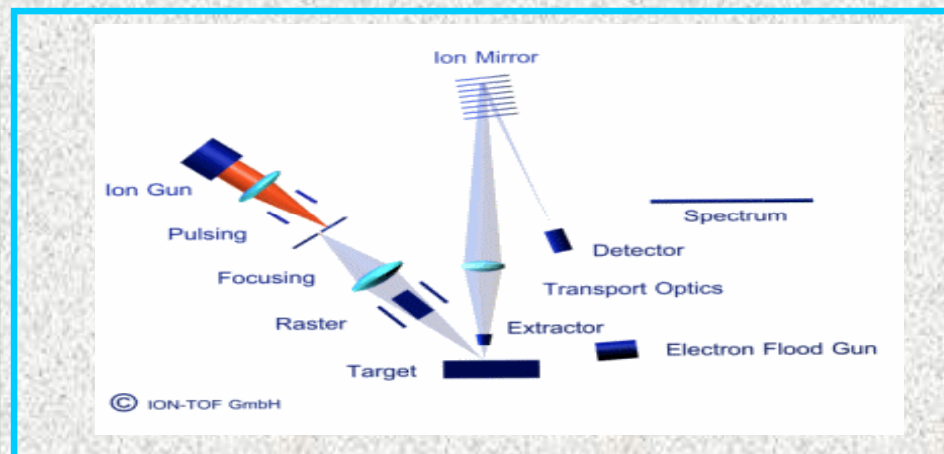


Secondary Ion Mass Spectrometer (SIMS)

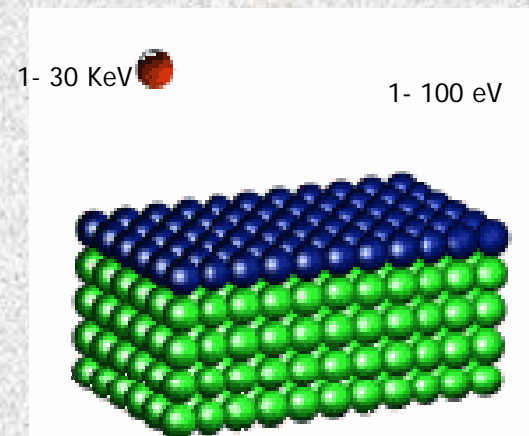


To develop understanding of impurity distribution near the top layer (~100 -200 nm) of niobium by 2-D, 3-D ion mapping of the impurities.

Quantification of the elemental impurity distribution using niobium standards .



- Red ball** : Primary ion
- Blue ball** : First atomic monolayer of the sample
- Green balls** : Inner layers

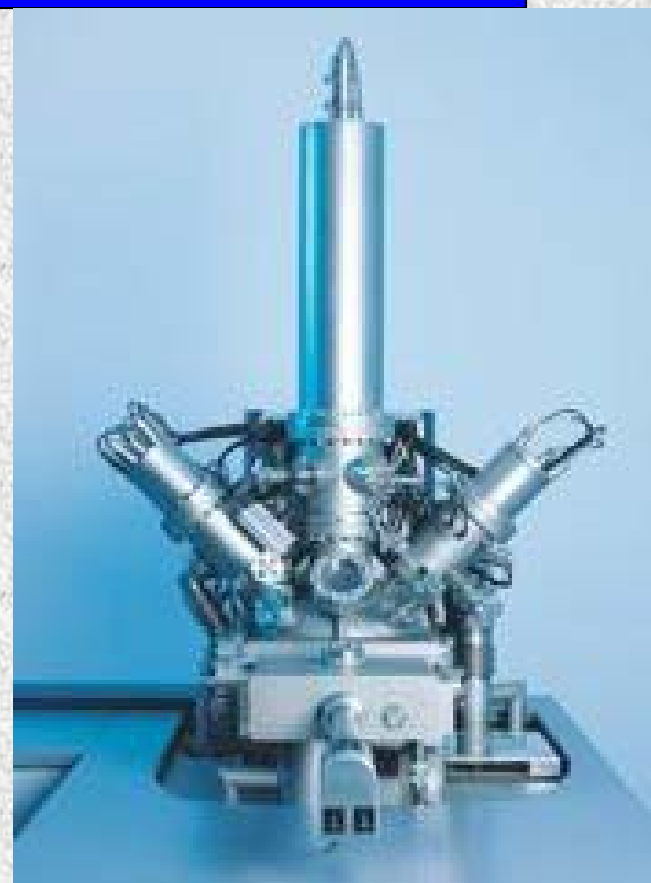




TOF SIMS 5 Specifications



Mass analyser	Energy focussing reflectron time-of-flight (TOF) analyser
Detector type	A combination of microchannel plate (MCP), scintillator, and photomultiplier for secondary ions detection.
Ion sources	Analysis source: Field emission cluster ion bismuth source Sputter source : Thermal ionization Cesium source & Electron impact gas ion source (Oxygen, Argon)
Mass range	1 – 10000 amu
Mass resolution	Better than 10000 at mass 29 amu
Detection limit	Better than 1 ppm
Depth resolution	1 nm or better
Depth profiling range	1 nm – 10 micron
Minimum Lateral resolution	150 nm or better with primary ion analysis gun
Base pressure reached after bakeout	$< 5 \times 10^{-10}$ torr
Sample size	100 mm x 80 mm or smaller sized samples
Specimen holder/manipulator	Sample heating and cooling (computer controlled, -150 °C to 600 °C) in the analysis chamber.



- **Purchase order placed.**
- **SIMS is expected to be delivered by Q3- 2011.**

3D Laser scanning confocal microscope

Imaging Method	3-D Laser Scanning Confocal system
Z - Resolution (Depth)	≤ 10 nm
Z - Measurement repeatability	12 nm
Z – measurement range	10 mm
X-Y Resolution	0.12 μ m



Olympus LEXT OLS 4000 Laser scanning confocal microscope

- Purchase order placed.
- The equipment is expected to be delivered by May 2011.

Cavity internal surface measurement using a small digital CCD camera with magnification 10X-200X



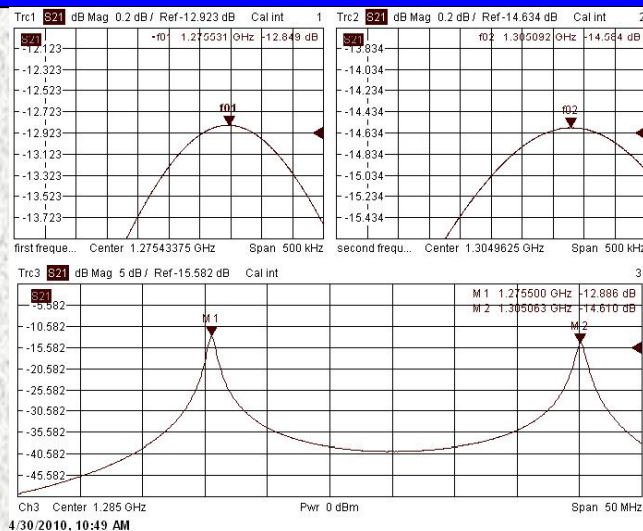
Motorized Optical inspection bench for cavity internal inspection (under development), it can accommodate 9 cell cavity



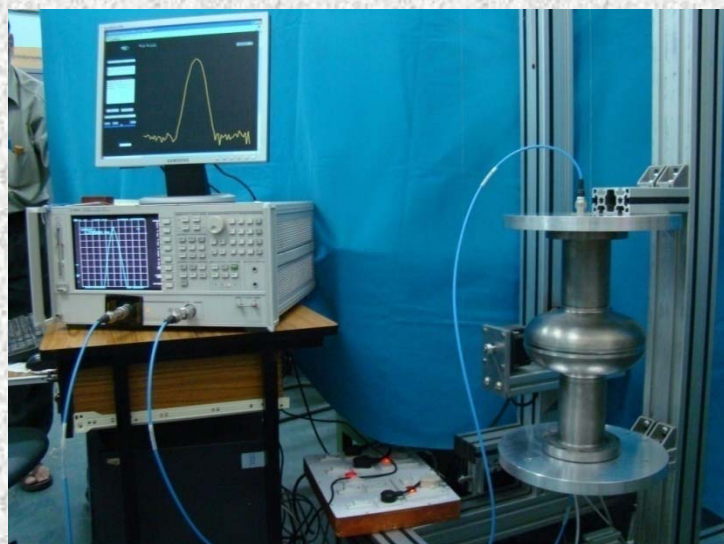
RF MEASUREMENT SETUP



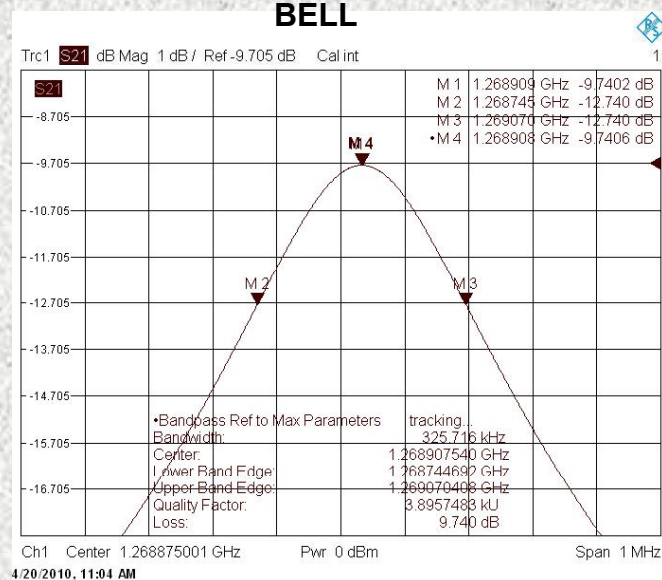
RF FREQUENCY MEASUREMENT SETUP



RF FREQUENCY PEAKS OF DUMB-BELL



RF MEASUREMENT SET UP FOR FREQUENCY AND FIELD DISTRIBUTION



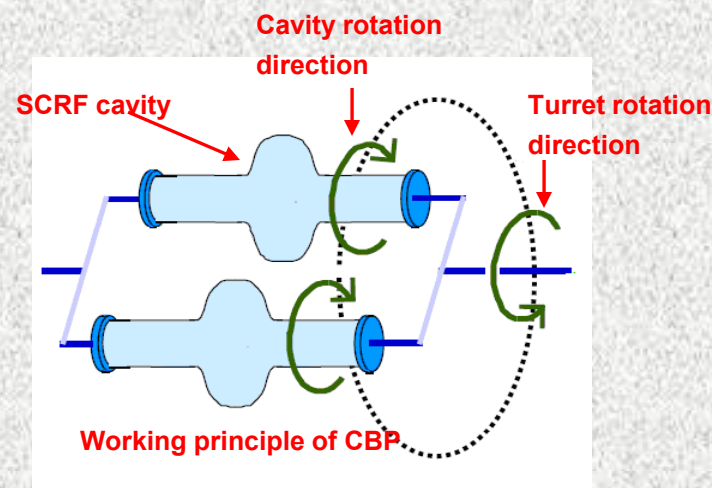
RF FREQUENCY PEAKS OF SINGLE CELL CAVITY

Cavity processing facility

- **Cavity Washing, degreasing**
- **CBP**
- **EP/BCP**
- **Thermal Processing @ 600⁰-800⁰ C**
- **Cavity Tuning**
- **HPR**
- **Drying & evacuation.**
- **Thermal Processing~120⁰C**

Main features of CBP machine

- ❖ Turret and Barrel rotate in opposite direction
- ❖ Turret speed – 0 – 200 rpm (variable)
- ❖ Barrel speed – 0 – 200 rpm (variable)
- ❖ Barrel size – 320 X 320 X 500 mm



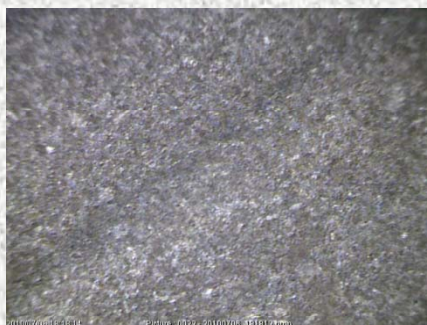
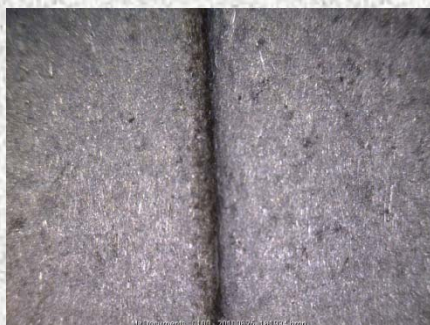
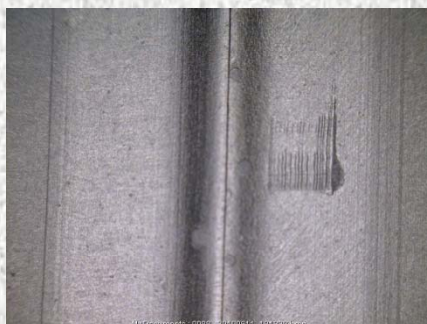
Cavity ready for mounting in CBP m/c



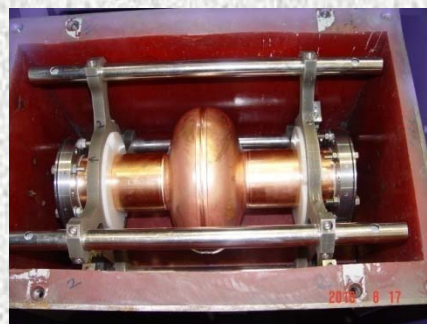
Cavities mounted in CBP machine

Initial Trial Results of CBP

Aluminum Cavity



Copper Cavity



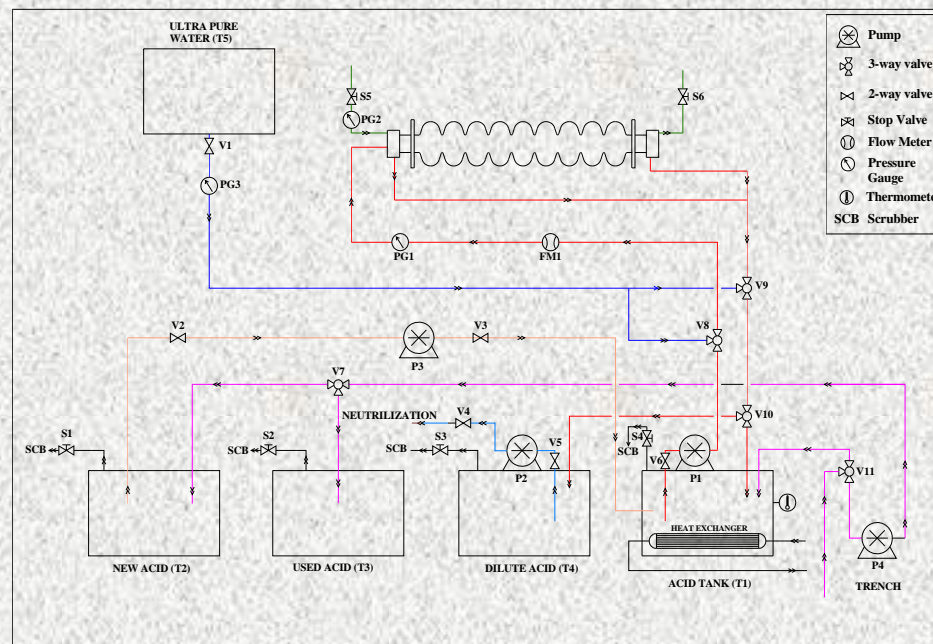
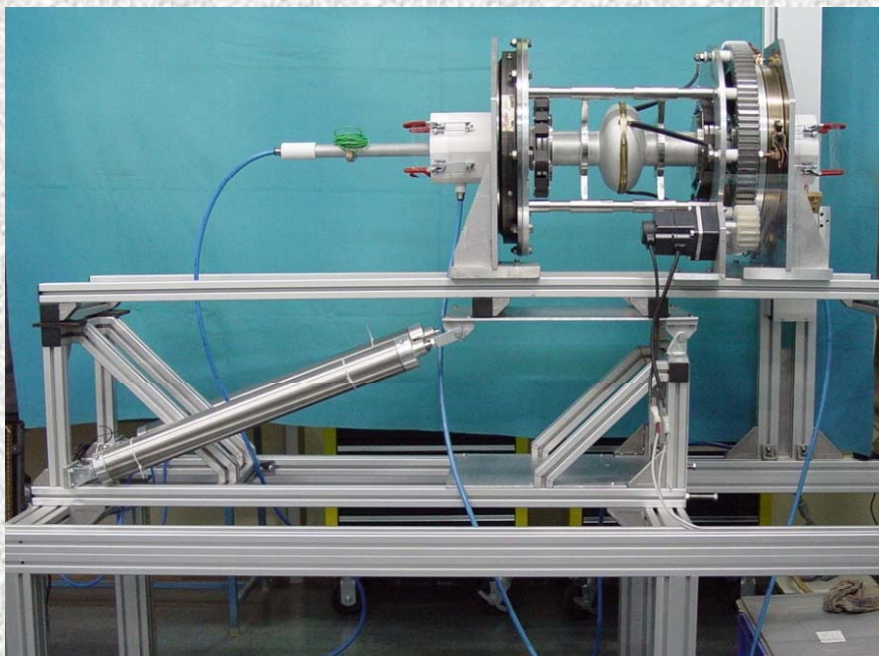
Ultrasonic cleaning facility



Ultrasonic cleaner for single cell cavity & small components



Ultrasonic cleaner for 9 cell cavities



Current density: $\sim 50 - 100 \text{ mA/cm}^2$
 Material removal rate $\sim 0.5 \text{ } \mu\text{m/min}$
 Rotational speed $\sim 0.2 - 1 \text{ rpm}$

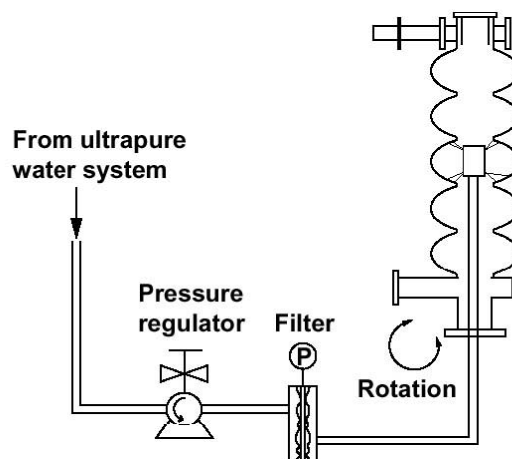
- Bench for electro-polishing of SCRF cavity has been developed, it can process up to nine cell cavity.
- Acid pumps, valves & plumbing for Sulphuric & Hydroflouric acid have been procured.
- 25V – 1000A DC Power supply has been procured.
- The hydraulic circuit has been tested with water

Features:

- Cavity / wand Rotational speed: 2-20 RPM
- Vertical Stroke: 1300 mm
- Vertical movement speed: 60 mm/min
- Ultra-pure water jet. pressure: 80 – 100 bar



Ultra Pure Water Plant



High Pressure Rinsing Set up in Clean enclosure (Class 100)

Specification of High Vacuum Furnace

Orientation	Horizontal
Temperature range	<u>Option-1</u> 1000°C Max <u>Option-2</u> 1400°C Max
Working Vacuum	<1 x 10 ⁻⁷ mbar (600°C -1000°C) <1 x 10 ⁻⁶ mbar (> 1000°C)
Working Volume	Diameter 400mm Depth 1500mm

- The procurement of high vacuum annealing furnace is in process.
- The facility is expected to be commissioned by mid 2012.

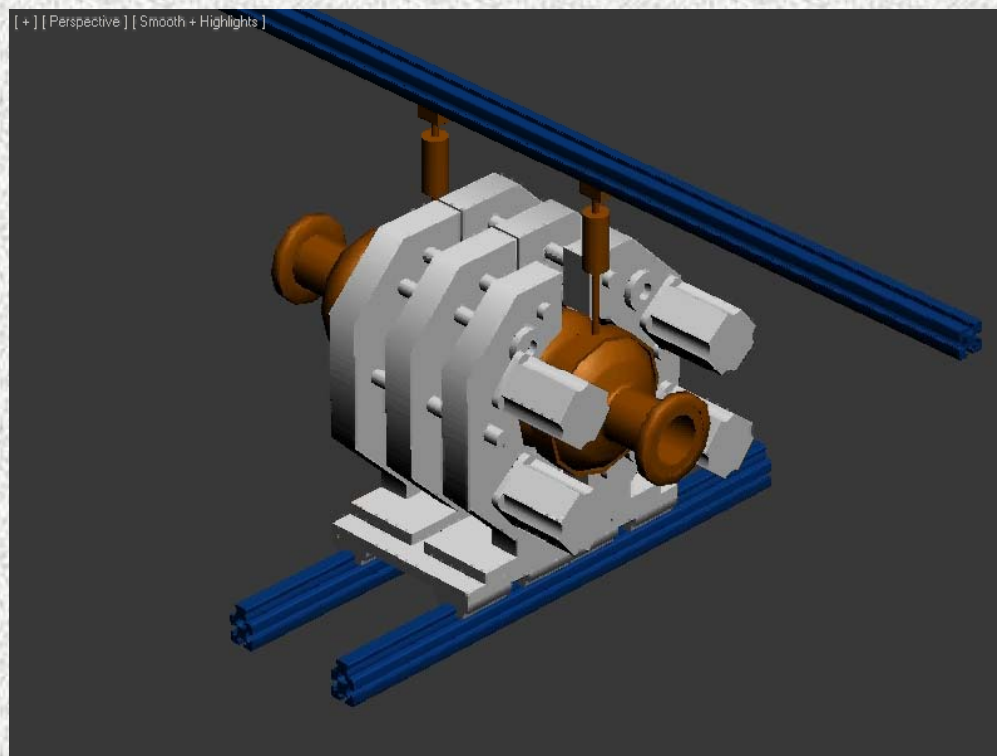
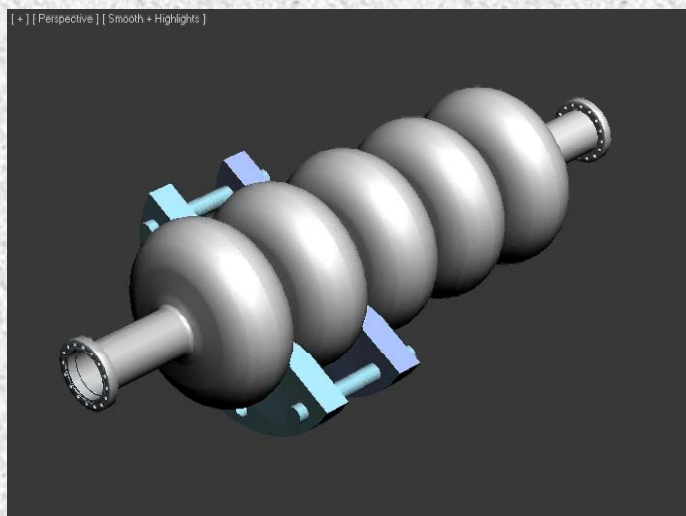


Tuning of SCRF Cavity

- A multicell elliptical accelerating cavity requires a “flat” electrical field profile at the target π -mode frequency
- $E_{min}/E_{max} > 0.98$

- Cavity requires cell to cell tuning due to shape deformation during fabrication, material removal at various stages of polishing & also deformation during thermal processing.
- Cavity must be straight & requires an alignment

Tuning Machine is needed for 650 MHz cavity



- A semi automatic tuning machine for 650 MHz cavity is being planned at RRCAT
- Fermi Lab has developed Instrumentation, software and integration for 1.3 GHz Automatic Tuning Machine (DESY, FNAL & KEK Collaboration). This expertise will be beneficial for IIFC to develop a tuning machine for 650 MHz.



Fermilab

Manual Tuning of single cell



Cavity testing facility

- **Engineering Design of VTS completed in collaboration with FNAL, USA**
- **Fabrication of VTS for RRCAT in progress with an US industry.**
- **Data Acquisition and RF Systems for RRCAT VTS in progress.**
- **Building for housing VTS & cryogenic infrastructure expected to be ready by**

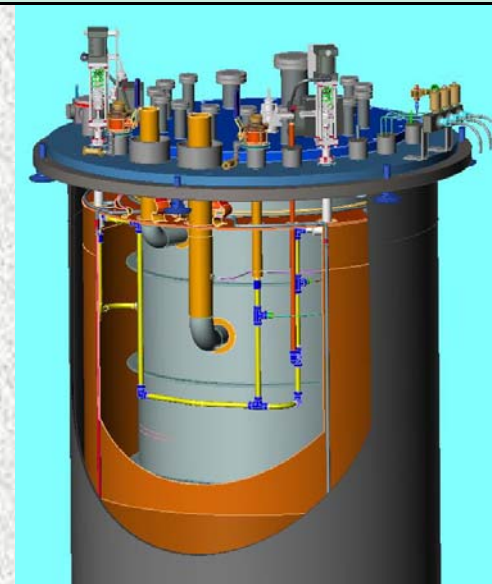


Development of VTS-2 in collaboration with FNAL



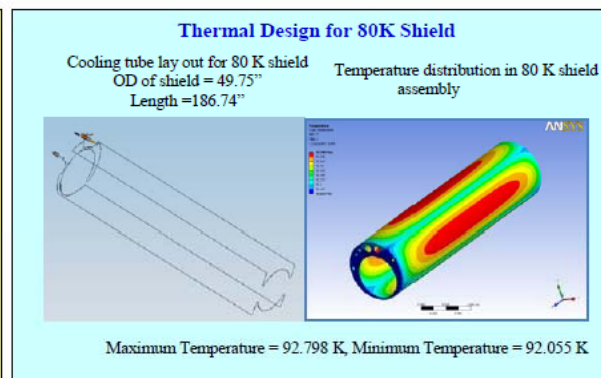
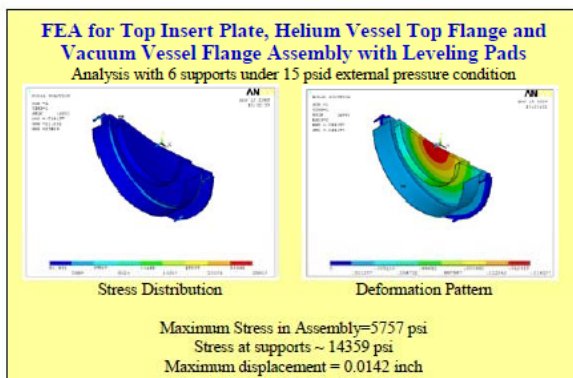
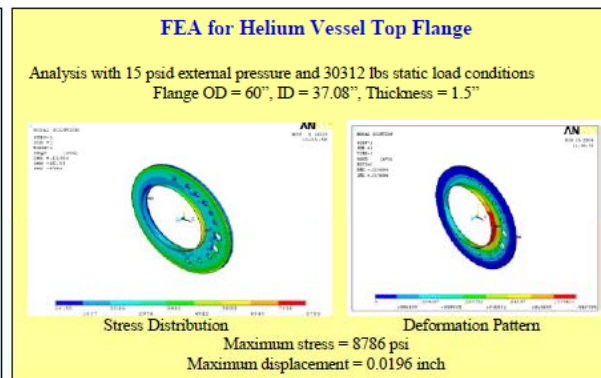
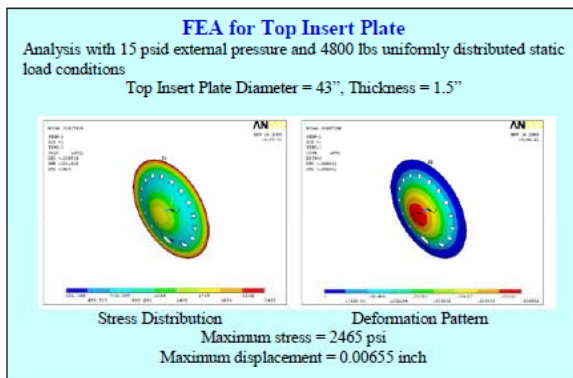
- ❑ Single & 9-cell Tesla-style cavities (2 – 6 cavities)
- ❑ Single Spoke Resonator cavity 325 MHz
- ❑ Triple Spoke Resonator Cavity 325 MHz
 - Measure Q vs. T ($T_{\min} \sim 1.5$ K)
 - Measure Q vs. E_{acc} at 2 K
- ❑ cryogenic capacity ~ 250 W at 2 K
- ❑ Magnetically shielded cryostat
 - External (room-temperature) Amumetal® (80% Ni alloy) and internal Cryoperm 10® magnetic shield, designed to attenuate field to < 10 mG at cavity
- ❑ Radiation shielding to maintain “Controlled Area” status
 - ❑ < 5 mrem in an hour immediately outside the shielding

Outside diameter of Vacuum Vessel + outside magnetic shield	≤ 58 inches
Length of Vacuum Vessel (from top flange to crown of head)	211.375 inches
Clear aperture of the Helium Vessel	34 inches
Length of Helium Vessel (from top flange to crown of head)	191.35 inches
80K Shield sits in space between Helium Vessel OD & Vacuum Vessel ID	



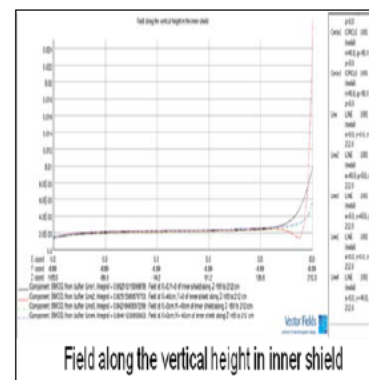
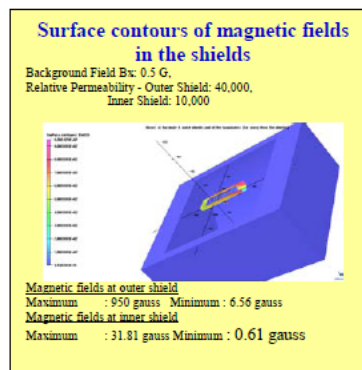


Engineering Design & Analysis of VTS Cryostat



MAGNETIC SHIELD DESIGN

Outer Magnetic Shield :	
Material	Amumetal
Diameter of shield	ID ϕ 54"
Thickness	0.0393"
Location of top of shield from top insert plate	10.75"
Location of bottom of shield from top insert plate	217"
Inner Magnetic Shield :	
Material	Cryoperm
Diameter of shield	ID ϕ 34.458"
Thickness	0.0393"
Location of top of shield from top insert plate	43.95"
Location of bottom of shield from top insert plate	185.67"



RRCAT & Fermi Lab jointly carried out design of design of various components of 2K VTS Cryostat:

- Liquid Helium Vessel
- 80K shield
- Vacuum Vessel
- Top Insert Plate
- Magnetic shielding (2K + room temperature)
- Piping layout for liquid helium
- 3-D model of the complete VTS-2 assembly

Three VTS cryostats are under fabrication at US vendor under joint supervision of engineers from Fermi Lab and RRCAT.

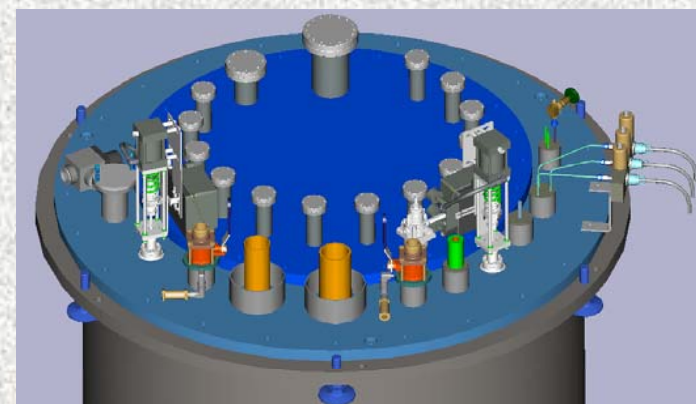
Expected delivery schedule : Nov 2010 – Feb 2011.

Building to house VTS at RRCAT is under construction and expected to be ready by Mid of 2011

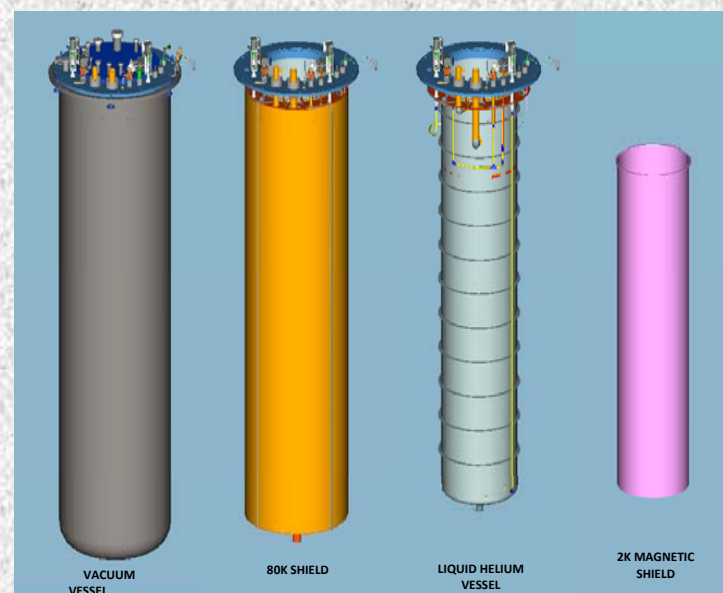
Cryogenics system under process (P K Kush & Team)

Components of RF and DAQ system fro RRCAT VTS is under process and expected to be ready by Dec 2011.

(P Shrivastava & Team – RF and T A Puntambekar & Team – DAQ)

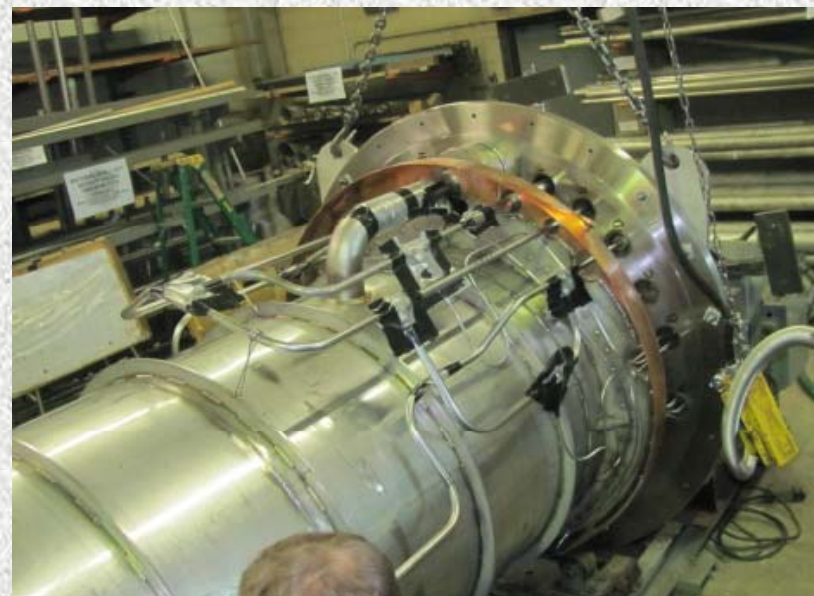


VTS-2 TOP PLATE – CRYOGENIC & VACUUM INSERTS

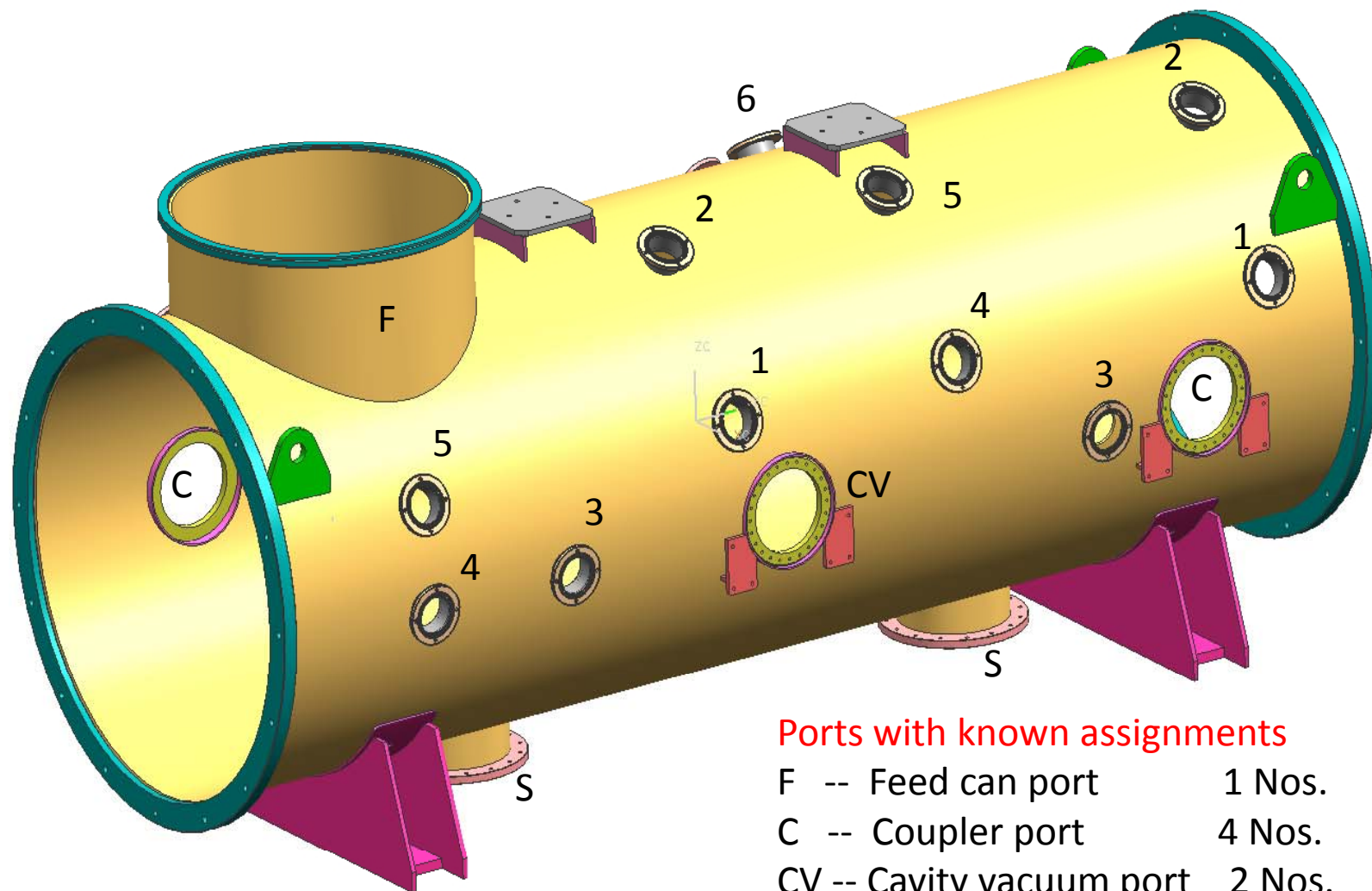


3-D MODELS OF VTS-2 VESSELS

Pictures of VTS under fabrication at vendor



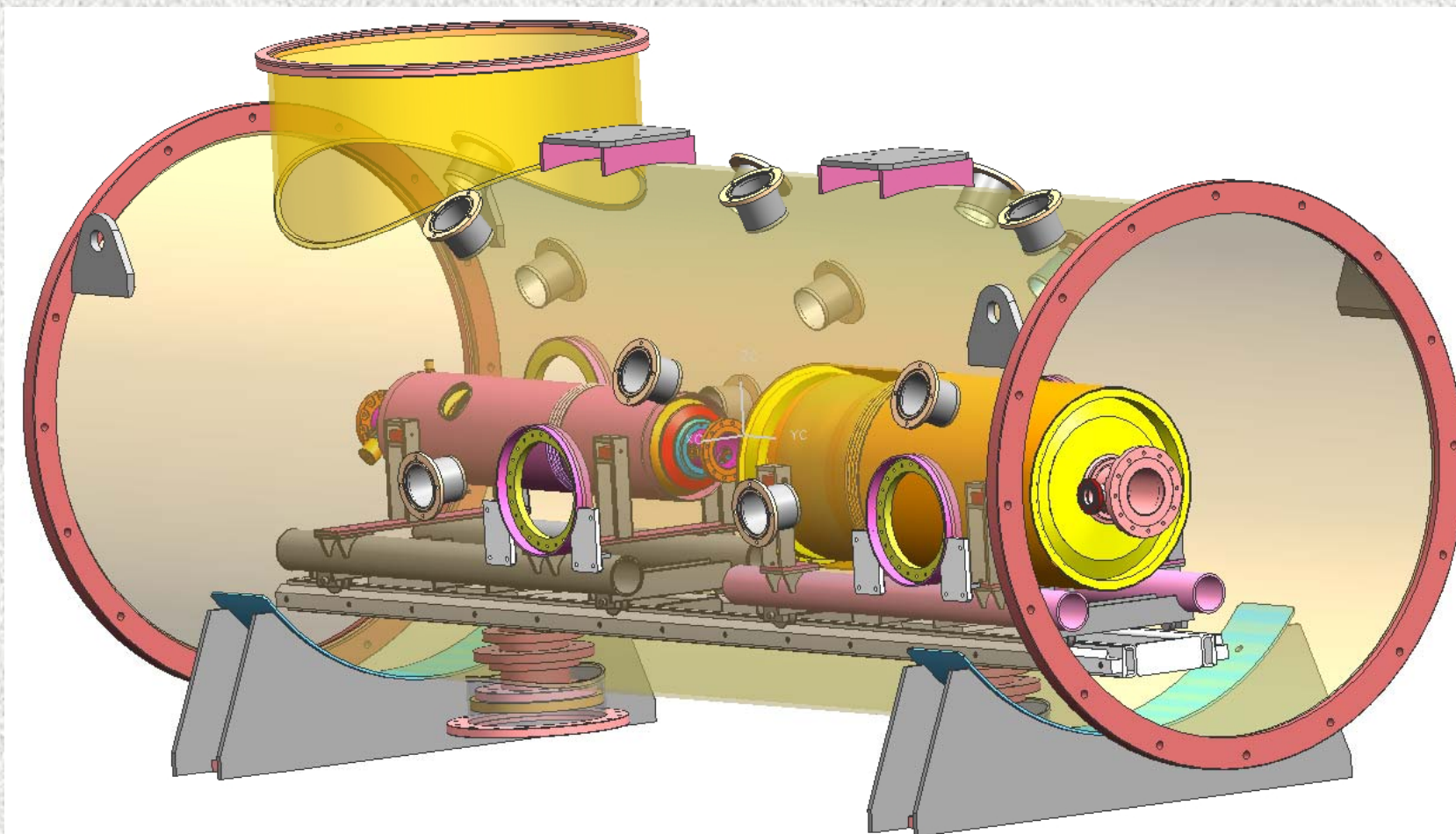
The 3-D Model of Vacuum Vessel of HTS-2 developed at RRCAT in Collaboration with FNAL



Ports with known assignments

F	-- Feed can port	1 Nos.
C	-- Coupler port	4 Nos.
CV	-- Cavity vacuum port	2 Nos.
S	-- Support post port	2 Nos.

HTS - 2



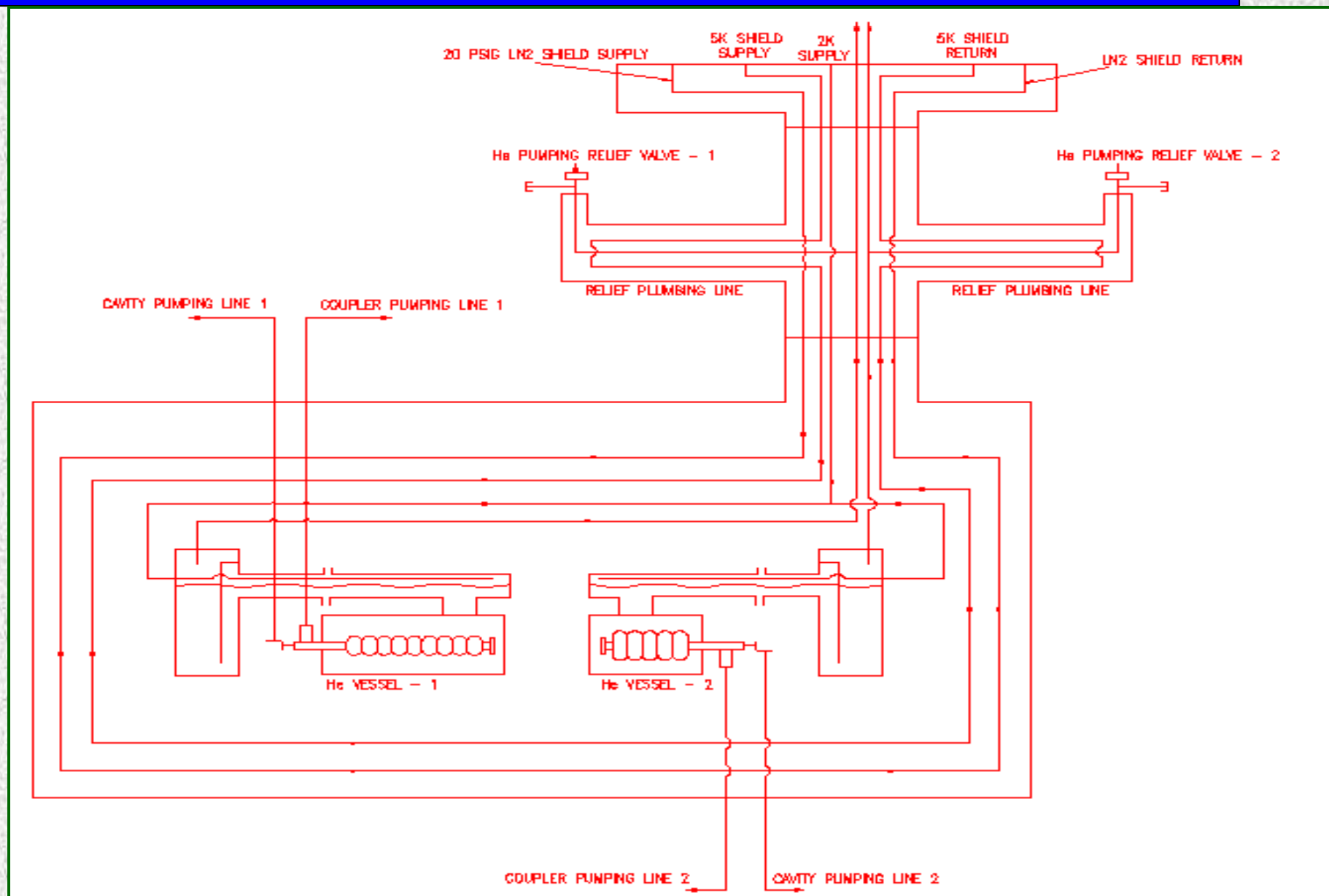


Required Specifications of HTS



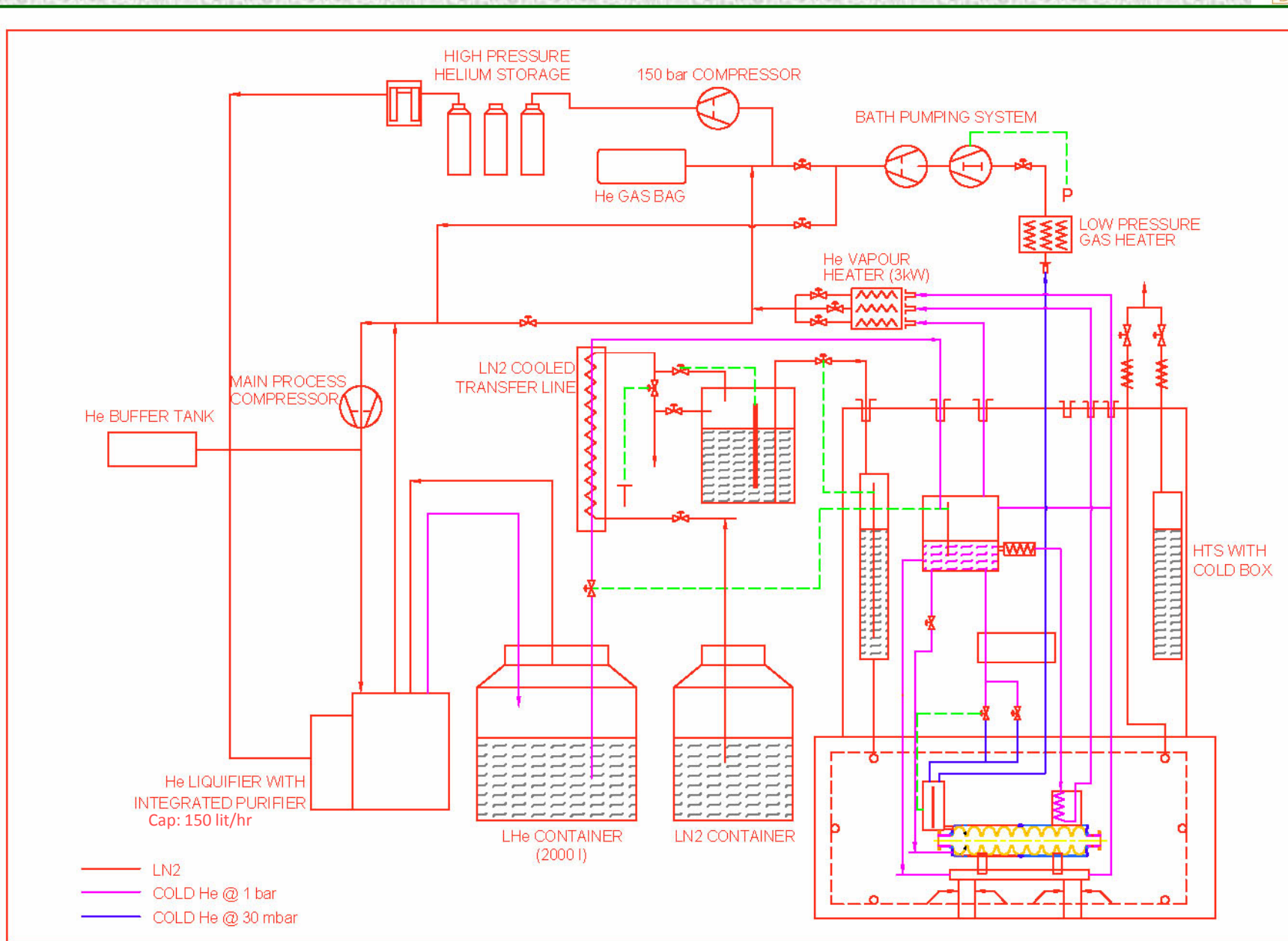
Parameter	Value
Mechanical	
Interior usable length	3.5 m
Interior diameter	0.965 m
Option for testing number of cavities	Two 9 cell cavities or operate as a cryomodule
Main Cryogenics	
Temperature	1.8 – 2.2 K, 4.2 K
Capacity	90 W/ 170 W (1.8 K/4.2 K)
Pressure Stability	± 0.1 mbar/1 mbar (1.8 K/4.2K)
Static losses	12 mW at 1.8 K (with 4 K shield) (without load of coupler and instrumentation leads)
Secondary Loop	
Table cooling loop	4.5 K
Cavity fill	4.5 K
Coupler cooling	4.5 - 20 K
Radiation shield	77 K
Vacuum Pumps	
Suction pressure	14 mbar
Speed	9000 m ³ /hr
RF Power	
Frequency	1.3 GHz
Power	10 kW

HTS-2 Cooling Circuit Option





Cryogenic Process Circuit proposed for Horizontal Test Stand

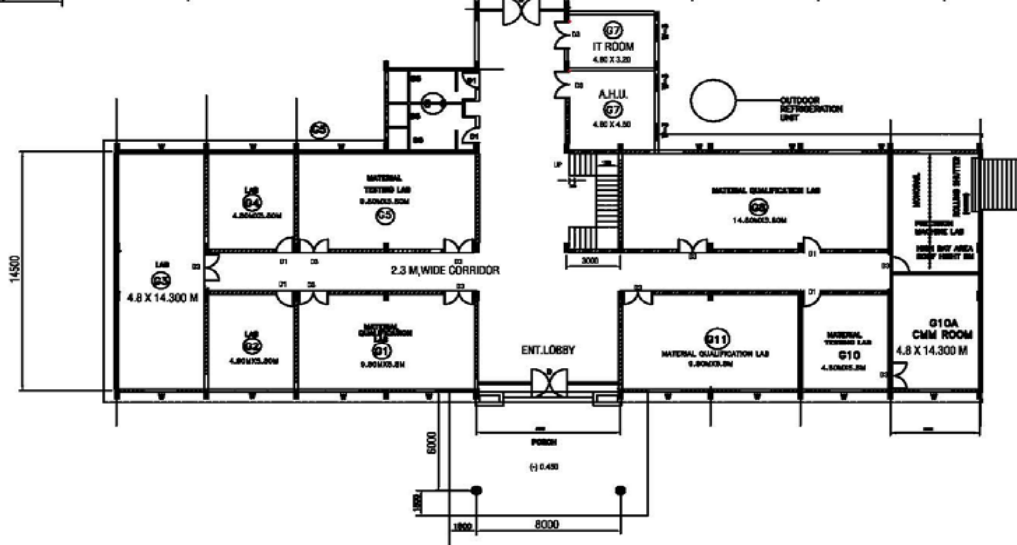
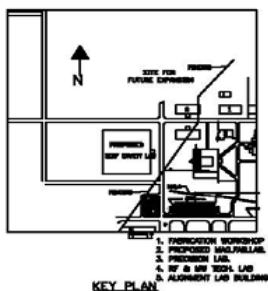
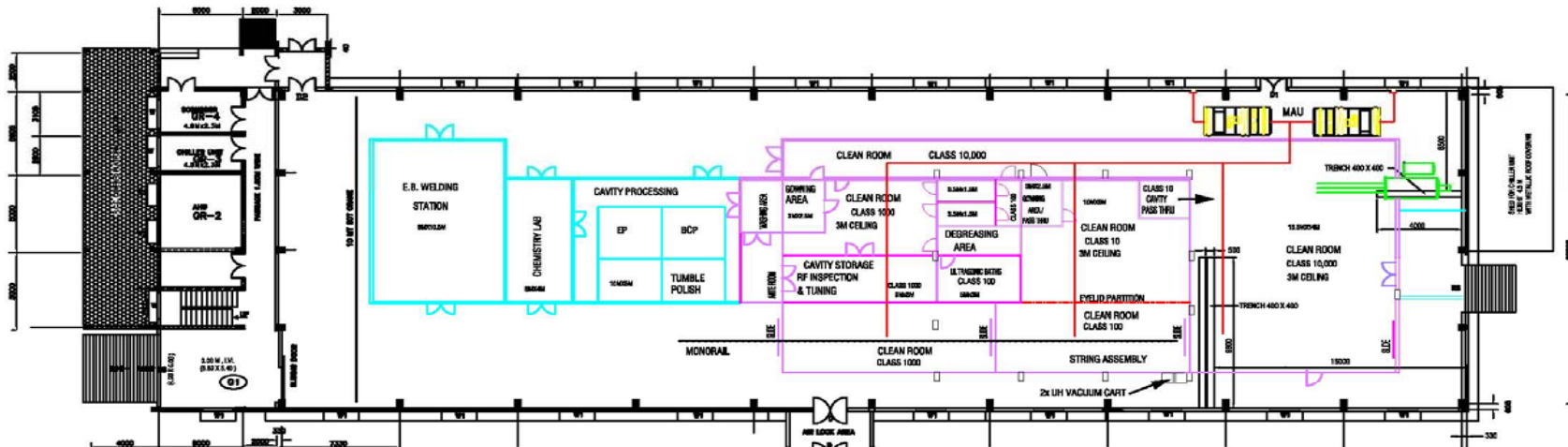




SCRF building & clean room facility



Building Plan for SCRF Facility



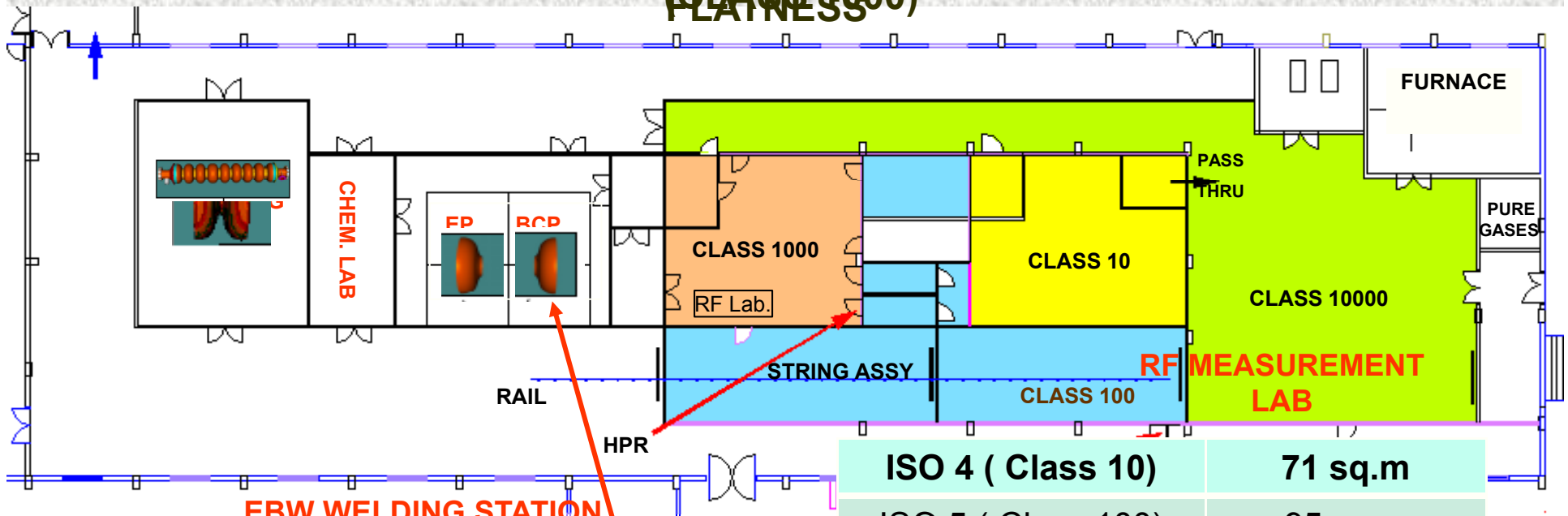


Fermilab

SCRF Cavity Movement in SCRF Building



TO DRYING VACUUM
 TO DRYING VACUUM
 CHEMICAL PROCESSING
 CAVITY MOVEMENT IN BUILDING
 HALLS
 MEASUREMENT LAB
 TUNING LAB
 WATER TREATING
 FLATNESS



EBW WELDING STATION
CAVITY PROCESSING AREA

ISO 4 (Class 10)	71 sq.m
ISO 5 (Class 100)	95 sq.m
ISO 6 (Class 1000)	113 sq.m
ISO 7 (Class 10000)	265 sq.m
Total Area	544 sq.m

Building for SCRF Cavity Development

Cavity Processing Building

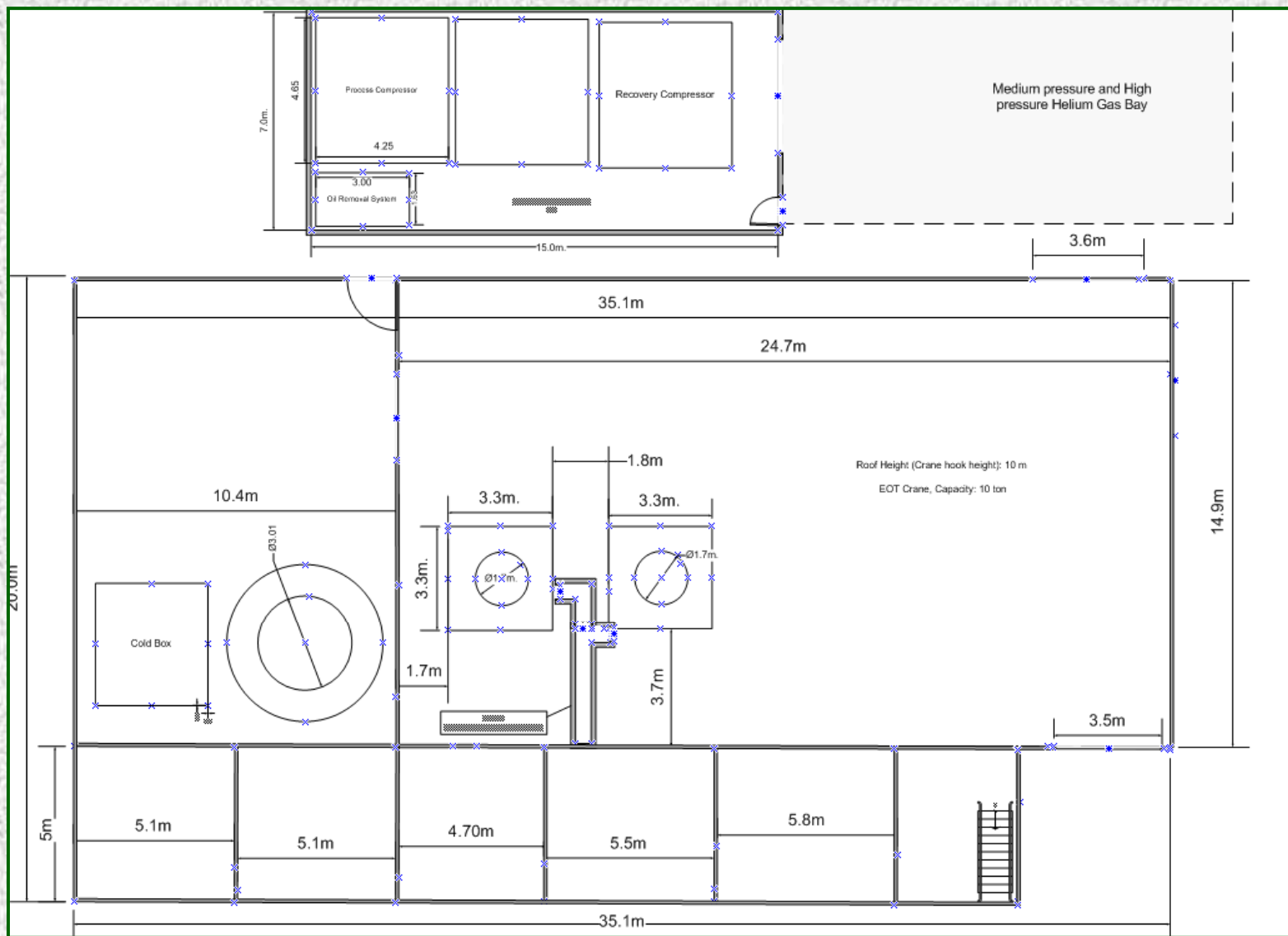
- Expected to be ready by Apr 11
- The building will house clean rooms, Electron Beam welding machine, High Vacuum Annealing Furnace, Electro-polishing setup, Centrifugal barrel polishing machine etc.

SCRF Lab Building

- Expected to be ready by June '11
- The building will house CMM, SIMS, material testing facility etc



Building for VTS/ HTS, Liquefiers and associated Helium gas handling Equipment





Status of Building during March 2011





Cryogenic Infrastructure



Present facilities:

- Liquid Helium: Linde TCF 20, Capacity 40 Litres/ hr
- Liquid Nitrogen: Capacity 60 liters/ hr

Facility Upgradation in process:

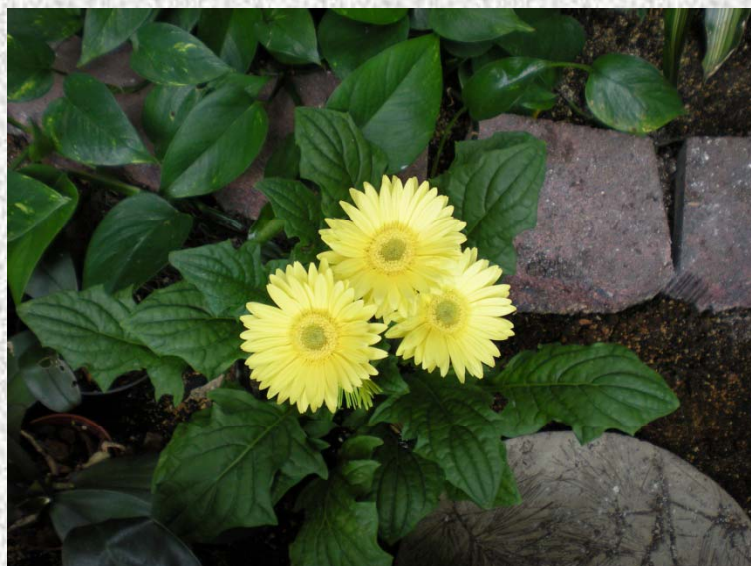
- Liquid Helium Plant 150 lit/hr
with 10,000 liter capacity main Dewar
- Matching High Pressure Gas Storage
- Helium gas recovery Compressors
- 2K Mechanical Booster pumps
- Cooling water chiller systems



Acknowledgement



- Dr S Banerjee, Chairman, AEC, Dr Anil Kakodkar, Former Chairman, AEC,
- IIFC Management for their support to SCRF Facility during project planning, review and execution.
- Dr Pier Oddone, Director Fermi Lab and Dr PD Gupta, Director RRCAT for continuous support and encouragement in speeding up of the activities.
- Fellow Project Co-ordinators S B Roy, P K Kush, KK Pant



Thank you